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Camilla Tossi et al.
Size- and density-controlled photodeposition of metallic platinum nanoparticles on titanium dioxide for photocatalytic applications
Size- and density-controlled photodeposition of metallic platinum nanoparticles on titanium dioxide for photocatalytic applications†

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Photodeposition has been demonstrated to be a reliable tool for the growth of co-catalyst nanoparticles on titanium dioxide. The current state of investigation on the technique, however, lacks a comprehensive study on the collective influence of different process parameters, preferring to confront the effect of a single parameter at a time. This paper presents a parametric study on photodeposition of platinum nanoparticles from liquid precursors on ALD-grown titanium dioxide, applicable to the fabrication of photocatalytic composite materials. In the described process, a systematic and rigorous statistical analysis of the photodeposition parameters is conducted, assessing the influential parameters that control and predict the size, density and loading of the deposited nanoparticles. The results are assessed by scanning electron microscopy, statistical analysis of micrographs, and X-ray photoelectron spectroscopy. This confirms the simplicity and the viability of photodeposition as a method for the self-assembly of metal nanoparticles from liquid precursors and provides all-round insight on the role of parameters such as the concentration of sacrificial reagents, the presence of H2SO4, and the concentration of the precursor solution, in the chemical and structural properties of the deposited nanoparticles.

A straightforward method for adding co-catalysts is the deposition of metal nanoparticles on TiO2: noble metals can additionally provide plasmonic enhancement to photocatalytic activity by the expansion of the light-absorption range, by hot electron injection and also thanks to resonant energy transfer from the nanoparticles to the supporting photocatalyst.

Photodeposition has been well established for decades as a technique for assembling metal nanoparticles. However, the interest of the scientific community in photodeposition has been steadily growing. One reason is the applicability in photocatalytic processes such as water splitting, decomposition of organic compounds and air purification from harmful hydrocarbons and even drug synthesis; another reason is the smaller environmental impact and the lesser costs, compared to methods that require a high temperature or an electrical bias.

A reliable control of the photodeposition results is necessary to avoid under- or overloading the co-catalyst, since an excessive deposition can lead to the coverage of the photosensitive material, or to such nanoparticle sizes where the smaller surface area hinders the photocatalytic activity. Moreover, the size of the platinum nanoparticles can affect the selectivity of the photocatalytic process. However, the joint influence of the

Introduction

Since its water-splitting properties have been demonstrated by the pioneering work by Fujishima and Honda,1 titanium dioxide has been exhaustively studied2 to assess its photocatalytic properties. In combination with its low cost, chemical and thermal stability,3 earth-abundance4 and non-toxicity when in bulk form,5 the photocatalytic activity of TiO2 makes it an attractive material for the production of hydrogen fuel6 and environmental remediation.9,10

The applicability of TiO2 is limited by its wide bandgap, which prevents the full exploitation of sunlight as a photocatalytic force,11,12 and also by the high recombination rate of charge carriers,13 which prevents efficient charge transfer to other media. One way of overcoming said limit is the addition of noble metals or other semiconductors as co-catalysts,14–16 thus facilitating the separation and the migration of photogenerated charge carriers,17 lowering the activation energy of reactions in water electrolysis,18 and suppressing photocorrosion in order to increase the stability of the semiconductor.19

† Electronic supplementary information (ESI) available. See DOI: 10.1039/c8ta09037h
parameters at stake (presence of sacrificial reagents, pH of the precursor solutions, structural properties of the substrate materials, thermal treatments) continues to be a topic in need of further investigation. While a large body of work exists on the effects of Pt doping or deposition on TiO₂ as far as the photocatalytic activity is concerned, less focus is aimed at the examination of the factors that jointly affect the fabrication.

The method hereby presented is pairing an efficient and fast recipe for the assembly of metal co-catalysts on anatase TiO₂ with a rigorous and straightforward statistical analysis of the experimental results of photodeposition of platinum on a TiO₂ substrate, tracking the influence of a full set of parameters with a small number of samples in order to still achieve a sufficient control over the size and the load of the nanoparticles. The photodeposited samples show densely packed platinum nanoparticles which are less than 10 nanometers in diameter. The statistical analysis determines the process parameters that more heavily influence the size and the density of the nanoparticles. In the present work, chloroplatinic acid (H₂PtCl₆) is used as a precursor, and the examined parameters are the concentration of methanol (used as a hole scavenger), addition of H₂SO₄ as a reducing agent, the precursor concentration, the purge time (to eliminate the dissolved oxygen), the intensity and duration of the illumination, and a thermal treatment of the substrates prior to the photodeposition.

The technique can also apply to TiO₂ nanostructures, favoring the localization of the noble metal particles, or nanopatterning, by selecting the exposed areas using an electron beam lithography mask. It is also implemented on other promising semiconductors, such as ZnO, WO₃ or CdS nanostructures, side by side with techniques aimed to improve the performances of semiconductors, such as crystal facet engineering and other optimizations of the shape and crystallinity in thin films and nanoparticles alike.

Experimental

Reagents and materials

Chloroplatinic acid, fluorine-doped tin-oxide (FTO) coated glass and methanol were acquired from Sigma Aldrich. In addition, glass cover slips with Teflon spacers (LifterSlip Microarray Glass Coverslips 22 × 5 mm²) were purchased from Arrayit Corporation.

Substrate preparation

Photodeposition surfaces were prepared by atomic layer deposition (ALD) of TiO₂ onto FTO-coated glass slides, using a Beneq TFS-500 ALD reactor (Fig. 1a(2)). The growth was carried out with 4500 pulses from water and titanium tetrachloride (TiCl₄) precursors at 250 °C, resulting in a 250 nm layer of anatase crystals (Fig. 1c(1)). After the deposition, the sample substrate was covered with photoresist to ensure surface cleanliness during storage. To remove the photoresist, the sample was ultrasonicated in acetone, followed by subsequent rinses in acetone, isopropyl alcohol, and de-ionized water (DIW) to remove any remaining organic solvents and then dried with a stream of N₂.

Prior to photodeposition, half of the samples underwent H₂ thermal treatment in a PEO-601/ATV furnace in a forming gas atmosphere with a flow rate of 3 L min⁻¹ and composed at 5% of hydrogen and at 95% of nitrogen. The samples were heated at a rate of 10 °C min⁻¹ to a temperature of 400 °C, held for 2 hours, then cooled with an N₂ purge. The samples were finally stored in N₂ atmosphere until the photodeposition.

Precursor solutions

In order to produce a 10 mg mL⁻¹ stock solution, 50 μL of 8 wt% solution of H₂PtCl₆ were diluted with 370 μL of DIW. To create the sample solutions, DI water was adjusted if needed according to the process parameters by adding H₂SO₄ to a concentration of 0.1 mM and then purged with N₂ gas for 30 minutes to remove any dissolved oxygen. Afterwards, the DI water, precursor stock, and sacrificial donor (methanol) were combined in the different concentrations to form the sample solution. Once a solution was prepared, 20 μL were taken and placed on the cleaned TiO₂ substrate surface (Fig. 1a(3)), then covered with a cover-slip mounted on Teflon spacers to create a 20 μL cavity (Fig. 1a(4)). Teflon tape was then used to seal the edges of the cover slip, sealing it to the substrate surface.

Sampling method

The process design method developed by G. Taguchi was used to determine the sampling required to explore the seven parameters mentioned in the introduction, with two levels for each parameter as illustrated in Table 1. Assuming that the parameters bear no influence on each other, but only affect the final result, eight is the minimum number of samples necessary to ensure that all the other parameters are represented in equal amounts, providing however unique combinations of every value of every parameters, which in turn enables to recognize the effects of the parameters. This is illustrated in the table in Fig. 1b, and this sampling scheme is called an orthogonal array. The choice of the processing parameters is discussed in the introduction and it was based on literature and on experimental tests that explored subsets of parameters in order to ascertain the lack of relative influence and the conditions that would lead to a successful photodeposition. The concentration values chosen for the methanol reagent are based on the study by Pan et al. in order to aim for a methanol content three orders of magnitude larger than the chloroplatinic acid, thus obtaining a solution rich in donor electrons. The concentration of H₂PtCl₆ stems from the work conducted by Herrmann et al., who assessed that a concentration higher than 2 mM, corresponding to value 1 in Table 1, led to a constant deposition rate.

Photodeposition

The sealed sample was secured to a sample holder with a built-in 4.4 mm diameter aperture. The sample holder was then placed facing a light source, as shown in Fig. 1a(5). A 1000 W Oriel model 66021 xenon lamp and Oriel MS257 monochromator set at 360 nm were used to expose the sample. The
light intensity at the sample surface was moderated by altering the distance between the sample stage and the monochromator output. The optical intensity of the light was measured with a S130VCSlim Sensor detector coupled to a Thorlabs PM100D power-meter. The two positions selected for this experiment resulted in optical intensities of 70 and 35 mW, which correspond to irradiances of 460 and 230 mW cm\(^{-2}\), respectively.

After the photoexposure, the samples were cleaned by subsequent rinses in DI water, acetone, and isopropyl alcohol, followed by a final DI water rinse, and then dried with N\(_2\).

**Characterization**

Characterization by surface imaging was carried out by a Zeiss Supra 40 field emission scanning electron microscope (SEM). The SEM micrographs were processed by applying a bandpass filter to increase the contrast between the TiO\(_2\) substrate and the nanoparticles in order to render a binary image: subsequently, mathematical analysis was performed in an effort to acquire the size, density and nearest neighbor distances of the particles, as well as to eliminate false particles (such as crystal edges). The details of the image analysis process can be found in the ESL.†

X-ray photoelectron spectroscopy (XPS) measurements were made using Kratos Axis Ultra system, equipped with a monochromatic Al Ka X-ray source. The spectra were measured with a 20 eV/40 eV pass energy and a 0.1 eV energy step. The energy
scale was calibrated to give 284.8 eV as the binding energy for the C 1s peak corresponding to adventitious carbon.

Results and discussion

The expected reaction between a metal in solution and TiO$_2$ is reductive photodeposition:\textsuperscript{26} $\text{M}^{n+1}\text{(aq)} + n\text{e}^- \rightarrow \text{M(s)}$, where oxygen vacancies in the semiconductor substrate act as traps for the photogenerated electrons\textsuperscript{35} allowing the adsorption of positive metal ions to the TiO$_2$ surface and their subsequent reduction\textsuperscript{46} to a solid phase. This basic reaction can therefore be supported by either encouraging the creation of oxygen vacancies, or favoring the attraction between the substrate and the metallic ions. Both factors are influenced by the choice of the precursor compound and by the following process parameters.

The pH of the precursor solution affects the reaction kinetics: a basic or neutral solution favors the formation of metal oxides,\textsuperscript{42,43} while a pH lower than the isoelectric point (IEP) of TiO$_2$ makes the surface adsorb positively charged ions\textsuperscript{44} such as H$^+$, attracting the platinum hexachloride ions to bond to the surface. In the present study, the solution was acidic in all cases, due to H$_2$PtCl$_6$ being an acid salt, with a pH ranging from 2 to 4 according to the concentration of chloroplatinic acid and to the presence of sulfuric acid. According to Wenderich et al.,\textsuperscript{26} the latter is likely to act as a reducing agent but since its concentration is low, it does not have the effect of dissolving the Pt nanoparticles as they grow.\textsuperscript{56}

The concentration of the precursor affects linearly the photodeposition rate for small concentrations before being overcame by the changes in the rate caused by other factors. Namely, the incident photon flux has a linear effect on the photodeposition rate until the precursor is depleted of metallic ions. The photodeposition time, instead, affects the size of the deposited particles\textsuperscript{45} as the metallic particles become favorable sites for further deposition.\textsuperscript{46,47}

The presence of oxygen vacancies increments with the concentration of sacrificial donors in the solution: the donors scavenge the photogenerated holes from the semiconductor,\textsuperscript{18} resulting to a longer lifetime for the electrons,\textsuperscript{49} which are now more likely to participate in the reductive photocatalysis. A high concentration of the sacrificial donor also yields lower valence states for platinum, favoring the deposition of metal rather metal oxide.\textsuperscript{50,51} However, if high amounts of oxygen are dissolved in the precursor solution, a competing electron scavenging reaction takes place: therefore purging the solution from the oxygen leads to an increased reaction rate and prevents oxidation reactions from taking place on the photocatalyst surface.\textsuperscript{52} An H$_2$ thermal treatment is also accounted in the parameters in order to create oxygen vacancies on the TiO$_2$ surface,\textsuperscript{57,58} which increase the electrical n-type conductivity,\textsuperscript{59,61} and the charge carrier lifetime,\textsuperscript{62} and act as nucleation sites for the nanoparticles.\textsuperscript{63}

Image analysis and statistical outcome

Fig. 2 shows the mean particle size and the particle density for all the eight samples: it is evident that there are no strong variations in the size from sample to sample, while dramatic changes are observed in the density. The variations are more clearly summarized in Fig. 3, which highlights the collective effects of the examined process parameters to both the size and density of the particles. The distribution of the particles appears uniform, which suggests that in this case the crystal orientation of the TiO$_2$ is not playing a major role in the preferred deposition sites, despite it being relevant in other photodeposition studies.\textsuperscript{64,65}

The details of the quantitative analysis are presented in Section 2 of the ESI: the statistical significance of the measured effects was tested using analysis of variance (ANOVA), the numerical results of which are presented in Tables S2–S5. As a test of null hypothesis, probability values (p-values) smaller than 0.05 indicate that a parameter has a statistically significant effect. Concerning the particle size, H$_2$ treatment, methanol concentration and light intensity were found to be influent factors, with respective p-values of 0.035, 0.012, and 0.047. For particle density, H$_2$ treatment and precursor concentration had a statistically significant effect, bearing p-values of 0.020 and 0.016 respectively.

The average particle diameter was in the 3–6 nm range for all samples, and the median of the particle diameter was slightly smaller than the mean particle diameter: this is compatible with the fact that the size of the particles follows a log-normal distribution, which is typical of particle growth by means of gas evaporation, coagulation and other random processes\textsuperscript{66} and Fig. S3 demonstrates the distribution of the particle sizes. The standard deviations for the mean particle diameter were between 1 nm and 3 nm, which are close to 50% of the average diameter: such a high variation is due to the small sizes of the platinum particles, as it increases the error during the image analysis. The particle density displayed a wider range, from 120 to 5000 particles per m$^2$, with clear trends, as portrayed in Fig. 3. It is also possible to assess a random distribution of the nanoparticles by verifying that the distribution of the nearest neighbor distances follows a Poisson distribution, as shown in Fig. S4 in the ESI.

The presence of platinum oxides is not expected in any of the samples, due to the pH of the precursor solution, which is lower than 5. However, samples numbered by 1, 4, 6 and 7 show signs of a peculiar mycelia-like particle formation in parts of the illuminated area (Fig. 1c(6) is an example), which is typical of
H2 thermal pre-treatment, which increased the oxygen vacancies. While the mechanism behind this is still being explored, this is in-line with previous results that show that Pt ions prefer deposition sites other than oxygen vacancies.44 At the same time, the less evident effect on the particle size is coherent with the fact that the average size is expected to be influenced by the conditions of the solution and of the illumination, as anticipated in the introduction.

Increasing the intensity of the incident light resulted in a smaller particle size. While this may initially seem surprising, increasing the incident flux would in turn increase the number of small Pt particles formed at nucleation sites, thus creating several different locations at which the growth reaction could proceed, causing the growth to be spread out across the sample, creating smaller particles undetectable by this analysis. Further, nucleated Pt particles act as recombination sites.45,46 Thus, a large number of Pt growth sites would inhibit the reaction. The influence on the intensity on the density, however, does not appear to be statistically relevant.

Higher methanol concentration resulted in larger particles, which is expected. According to literature, the kinetics of photodeposition in the presence of the sacrificial reagent develop as follows:48 at first there is adsorption of [PtCl6]2− to the semiconductor in darkness, followed by a two-phase consumption of the metal from the solution, first at a slow rate and then at a faster rate until the precursor solution is depleted. Furthermore the UV-illumination has produced methanol radicals, electrons are provided for the reduction reaction, helping it to proceed more readily, and the favored locations for it to take place are the particles that have already been deposited.49 In absence of methanol the photodeposition rate remains in the slow phase and complete depletion does not happen. In addition, the absence of methanol has been demonstrated to encourage the formation of platinum oxides, which corroborates the observation of smaller metallic particles as well as the presence of oxide on samples that have both higher pH and low methanol concentration.

Higher precursor concentrations resulted in smaller particle densities. As mentioned, the photodeposition rate of platinum is not limited by low precursor concentration, except at very low concentrations.41 A concentration of 1 mg mL−1 was sufficient to provide ions for the reaction, so the higher particle density due to lower precursor concentration could be a result of decreased interactions between platinum ions. In general, due to the metal atoms adsorption, the upward shift of conduction band edge will improve the reducing capacity of TiO2 already when a single platinum atom succeeds in depositing on the semiconductor.71 This would lead to an increased adsorption on the TiO2 surface. Alternatively, at high precursor concentrations, particle nucleation may occur faster, which would allow the smaller and less stable particles to dissolve, resulting in larger particles which, in turn, brings an overall decrease in the particle density.

Within the confines of the present experiment, the changes in N2 purge time and methanol concentration did not have a significant effect on the final density. While the statistical analysis did not show that the addition of H2SO4 had a significant effect on the size and density results, the presence of the acid in the solution is nevertheless important, as it favors metallic platinum, as previously mentioned, and further elaborated upon in the Section 3 of the ESI.†

### Applicability to gold photodeposition

The procedure was successfully conducted not only with a platinum precursor, but also using gold(III)chloride trihydrate (HAuCl4·3H2O) in order to deposit gold nanoparticles,32,46,73 with the only process difference of shorter deposition times. The results were straightforward, especially thanks to the lack of a competing metal oxide deposition and to the larger particle size, and strikingly similar to their platinum counterpart in

<table>
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<th>Metallic Pt</th>
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terms of the effects of the deposition parameters. Further elaboration on the gold-deposited samples can be found in Section 4 of the ESI.

Conclusions

From the results hereby presented, it is evident that the procedure yields successful results in metal photodeposition, and clearly shows the influence of the process parameters on the final results. Based on the particle analysis, in order to achieve small but densely packed metallic platinum nanoparticles, one should aim for low light intensity, low sacrificial agent content, low precursor concentration, addition of H2SO4, and acidic pH. The acidic pH should be selected in all cases, in order to achieve metallic nanoparticles, as platinum nanoparticles have shown to be more photocatalytically active than platinum oxides.67 The H2 thermal treatment should not be conducted, since it was shown to decrease the particle density more drastically than the particle size. Platinum particle sizes remained relatively small for all of the samples, regardless of the parameters used. This is a welcome result, as the small particle size has been proven to have a profound effect on the photocatalytic activity while large co-catalyst particles can shadow the active sites on the surface of the photocatalyst, and serve as recombination sites, causing electron–hole pairs to recombine rather than contribute to the reaction.69,70 Because of their slow growth during photodeposition, the size of the platinum particles is easy to control by altering the deposition time and the amount of precursor, while the overall changes appear to be more drastic in regard to the density of the nanoparticles, showing that the deposition parameters deeply affect the total load of the co-catalyst on the photocatalyst surface.

This study provides a straightforward instrument for selecting, from a list of process conditions, the influential parameters on size and density of photodeposited particles, which allows for the optimization of the co-catalyst loading; furthermore, it can be expanded to comprehend factors that are normally investigated separately from the strict photodeposition.4 The success of the procedure can also contribute to wet-synthesis processes of novel structures,74 as well as in situ photo-deposition during a photoelectrochemical process such as water-splitting, hydrocarbon reduction to CO2, all methods that benefit from the use of methanol as a sacrificial reagent.75

Conflicts of interest

There are no conflicts to declare.

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